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Annelies Delabie is a principal member of the technical staff at imec, research institute for nano-electronics and digital technologies in Leuven, Belgium, and a professor in the faculty of science at the University of Leuven (KU Leuven) in Belgium, where she started the “Nano-engineered thin films” research group in 2012. She received her PhD degree in science from the University of Leuven in 2001. Her research focusses on the fundamentals and applications of thin films and thin film deposition, with a focus on Atomic Layer Deposition (ALD), Chemical Vapor Deposition (CVD) and Area-Selective Deposition (ASD). She is (co-)author of 10 patents and more than 220 scientific publications. She is a member of the committee of the American Vacuum Society (AVS) international conference on ALD since 2006, and she co-chaired the AVS ALD conference in Brugges in 2008. She is also a committee member of the ASD workshop, and she chaired the ASD workshop in Leuven in 2016.